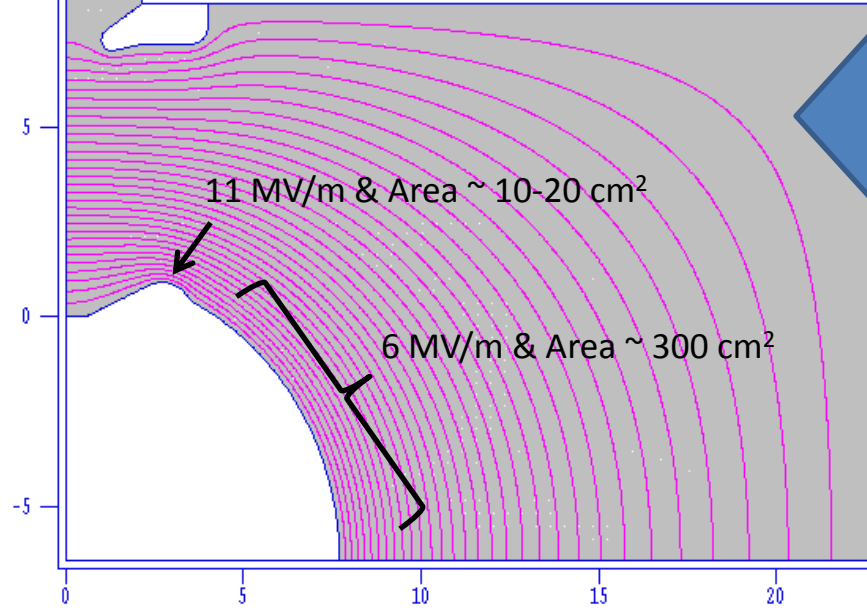


350kV @ 7cm gap
(C. Lopez)



We know HV & gas processing necessary step, and likely necessary in-situ.

Now = Process in Test Stand + Run in Tunnel

Future = Sure, process in tunnel, but lose gradient capability.

Develop a HV chamber that provide:

Normal beam capability

+

Test Stand –like Processing capability

350kV @ 7cm gap
(C. Lopez)

